

Notice of References Cited

 Application/Control No.
 09/693,012

 Applicant(s)/Patent Under
 Reexamination
 BOYERS ET AL.

 Examiner
 Gentle E. Winter

 Art Unit
 1746
 Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-5,716,458	02-1998	Machino, Katsuya	134/1
*	B	US-5,567,444	10-1996	Hei et al.	134/2
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
*	U	The Effect Of Temperature on an Ozonated Water Photoresist Strip Process by Nelson et al.
*	V	Decomposition of Ozone in Aqueous Acetic Acid Solutions by Sehested et al.
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
 Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.